

Introduction of FOLP[®] technology

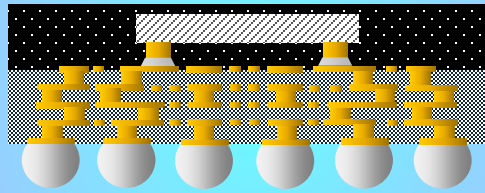
FOLP[®] (Fan-Out Laminate Package)/ FOPLP

High frequency application

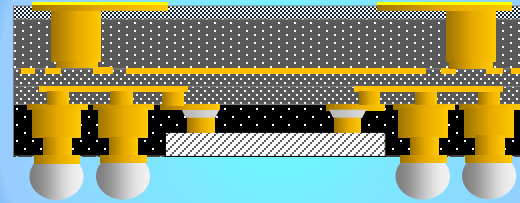
Logic application (Chiplet integration)

Power Module application

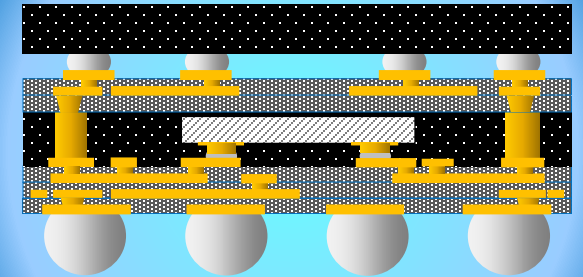
High frequency application



RF control device

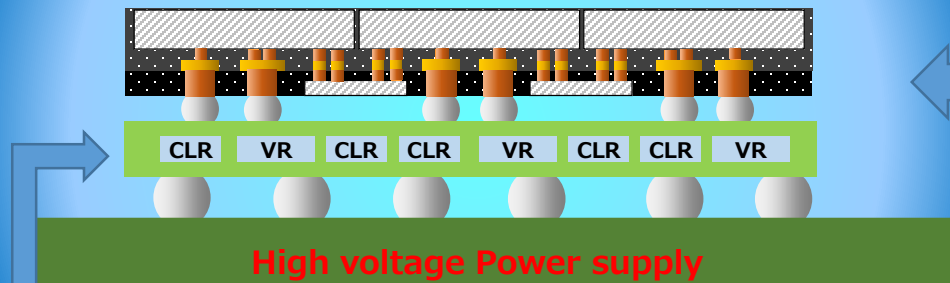


Antenna in Package



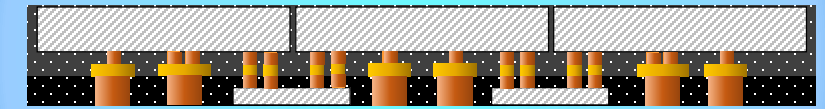
POP

Logic application (Chiplet integration)



High voltage Power supply

PSB



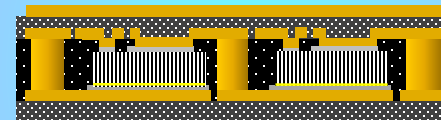
MetaIC

Power Module application

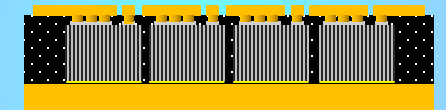


Power supply module

High heat dissipation, Thin



Inverter



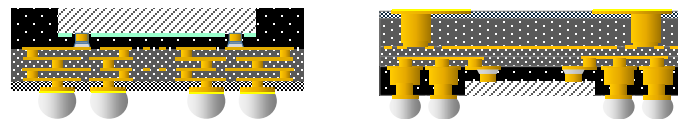
MetaFET

FOLP[®] Technology Direction (Trend)

RDL-first (fine pitch/multi-layer)

High Frequency

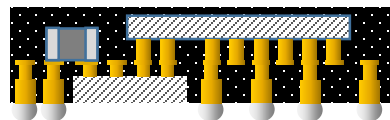
Multi-Layer, 3 D FOLP[®]



High Via connection reliability
Deep plugged Via
Low RF signal loss
(Low Df material)

Logic

Fine pitch FOLP[®] Chiplet



Fine pillar pitch
Fine Line/Space
High yield (Simple structure)

Chip-first (high heat dissipation/low resistance)

Power Module

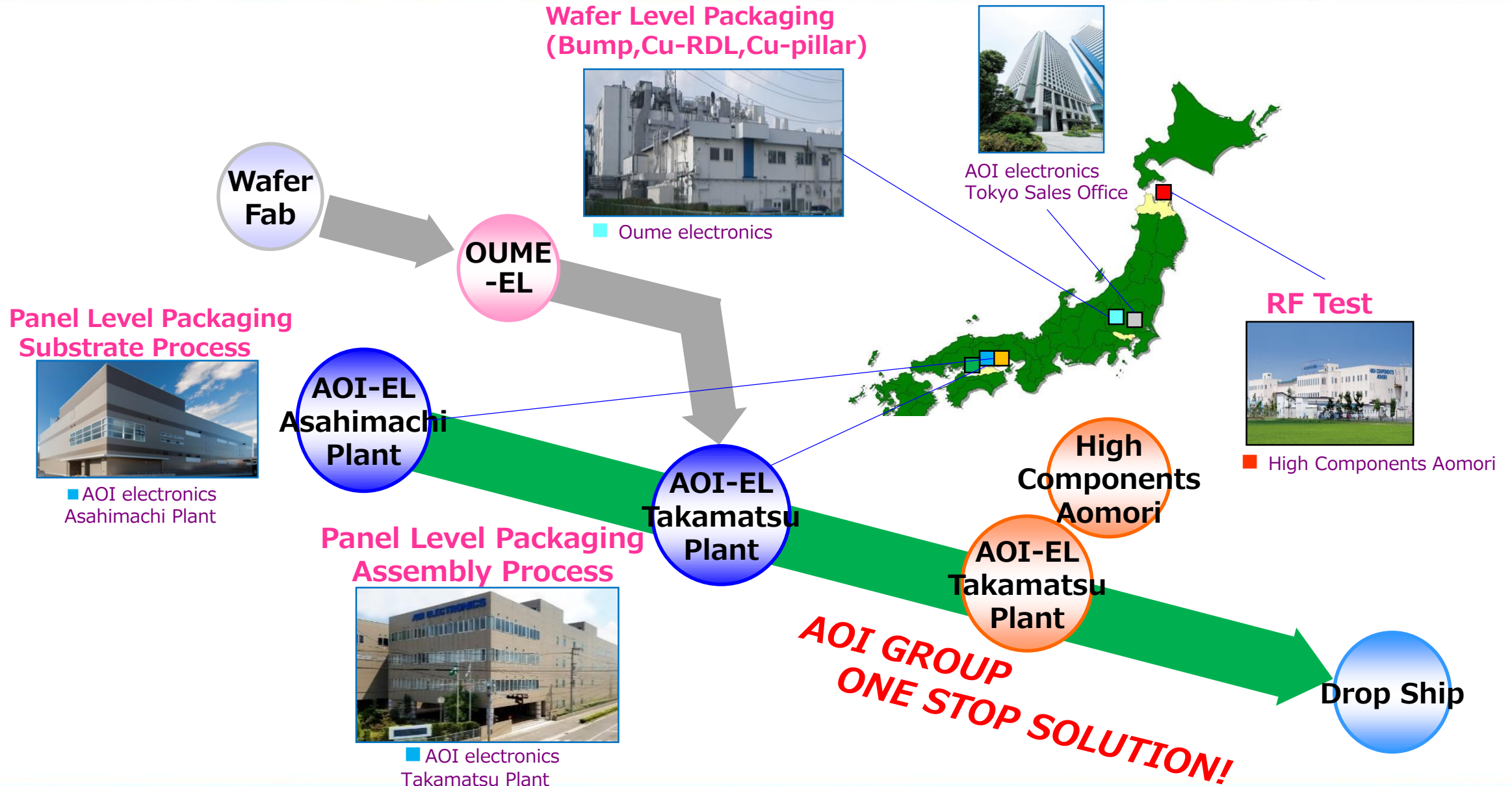
Thinner , Heat dissipation FOLP[®]



Low electrical resistance wiring
Low inductance wiring
High heat dissipation
(High thermal conductive material)
High operation temperature
(High Tg material)

Warpage control

FOLP[®] Production Platform



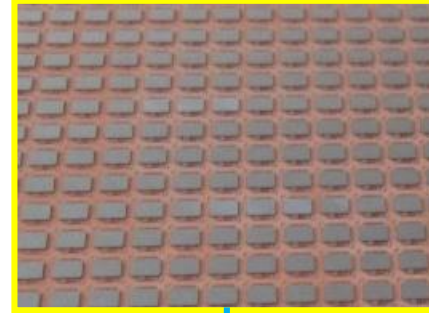
FOLP[®] *for High Frequency application*

FOLP[®] Elemental technology (1)

RF controller

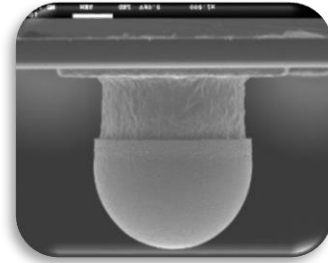
FC-Bonding

Si, SiGe, GaN, GaAs, Others (100 μ mt)

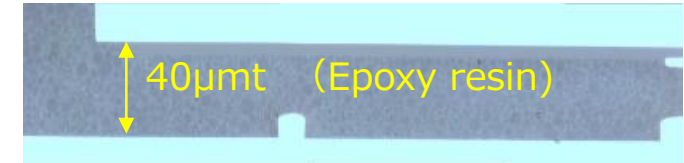
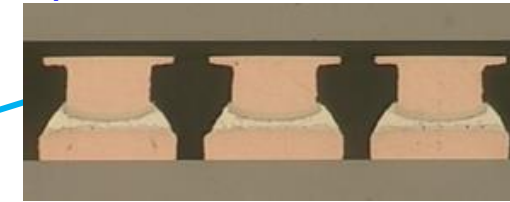


Cu Pillar Bump

40 μ m ~ Pitch

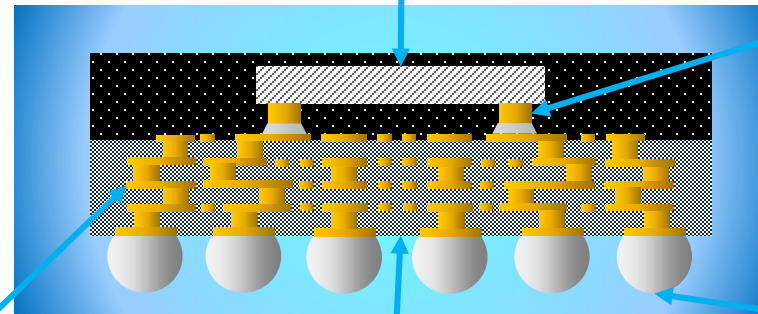
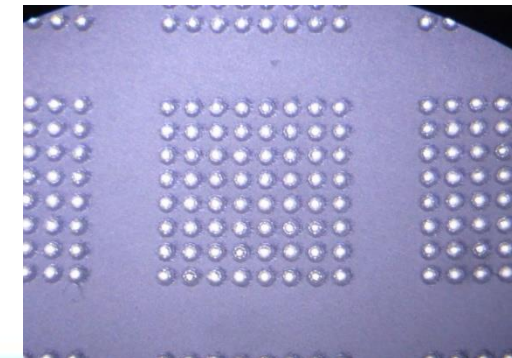


C2 bonding & encapsulation



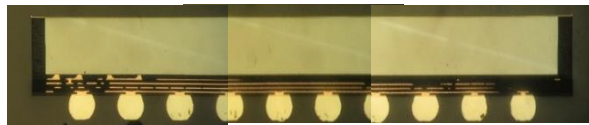
Solder Bump

SAC, SACN, SACNBi Others

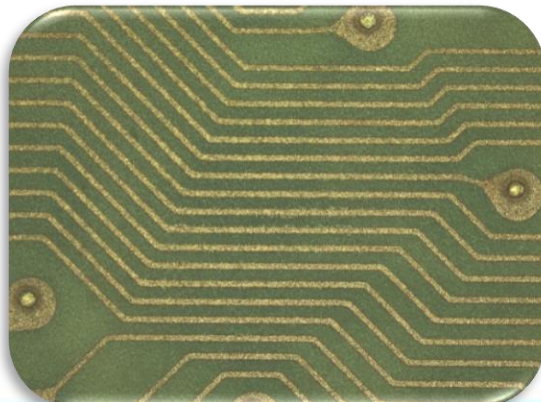


Low stress insulator

CTE (25~150 $^{\circ}$ C) 14ppm
Young's modulus 10GPa



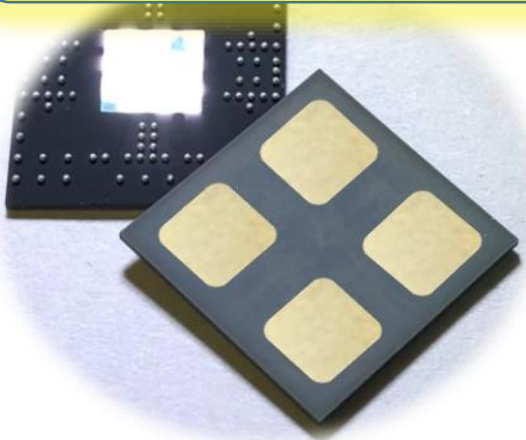
Fine Pitch RDL (Line=10 μ m)
(Max 5 Layers in MP, 8 Layers in trial)



FOLP[®] Elemental technology (2)

Applied Model

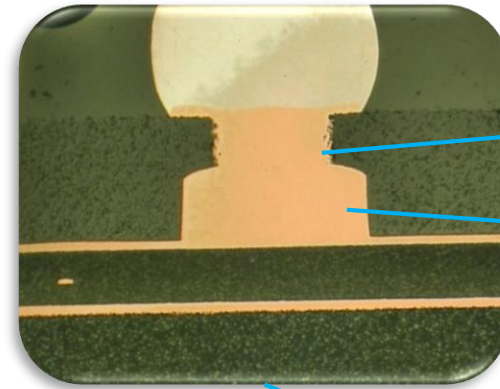
AiP Case



Backside Grinding



ToM(Terminal on Mold)



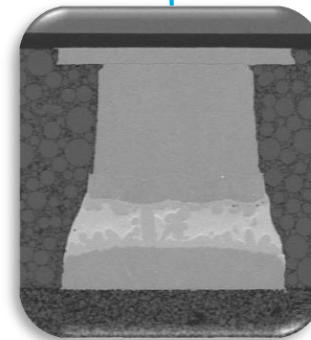
TRV(Through Resin Via)
+
Cu Post



Resin

Accurate Via
alignment
on antenna

Low Df Isolation
(0.002 ~)

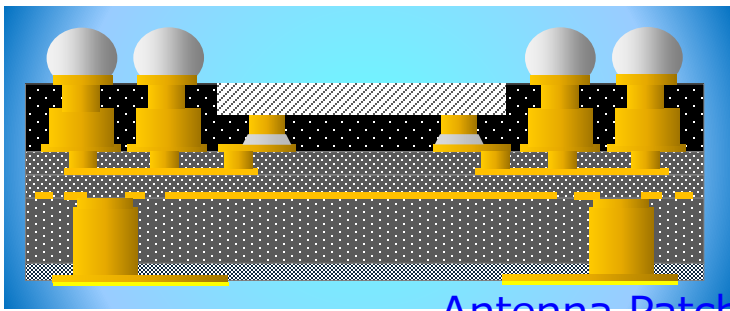


C2 bonding



200~400µm

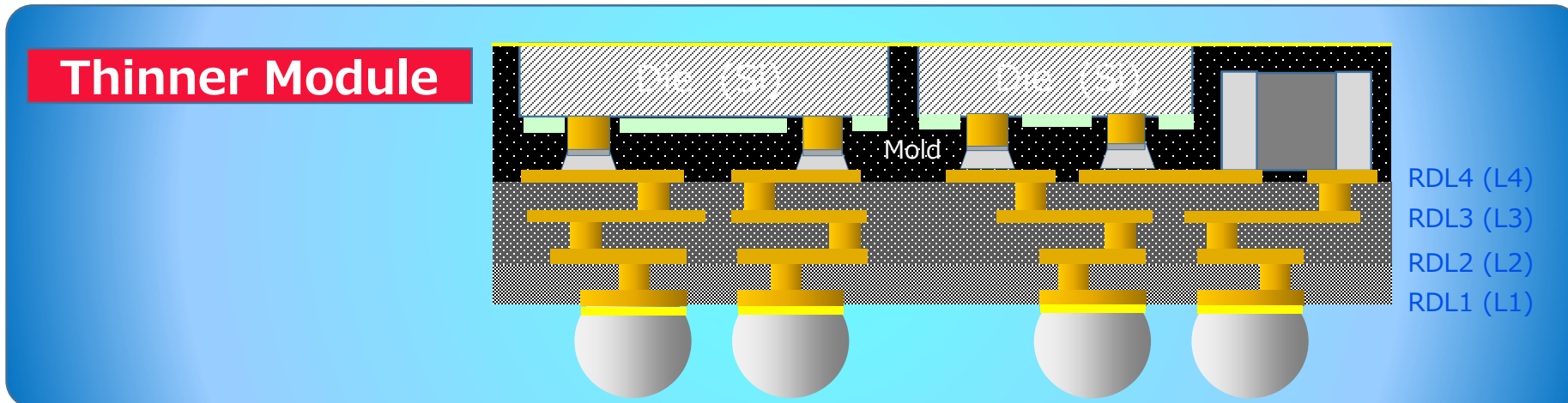
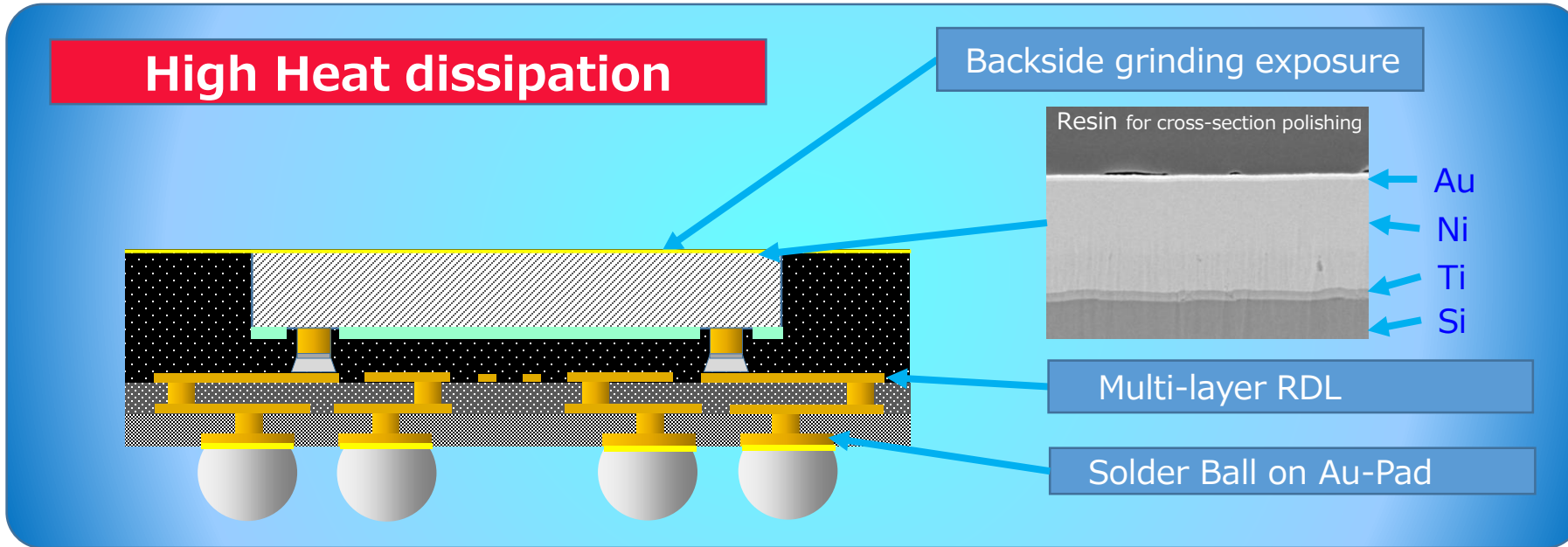
PLUG(Plugged Via)



Antenna Patch



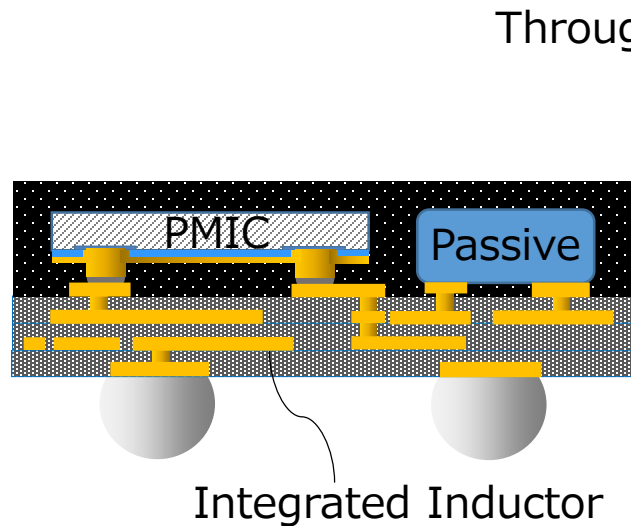
Active+Passive device FOLP® Module



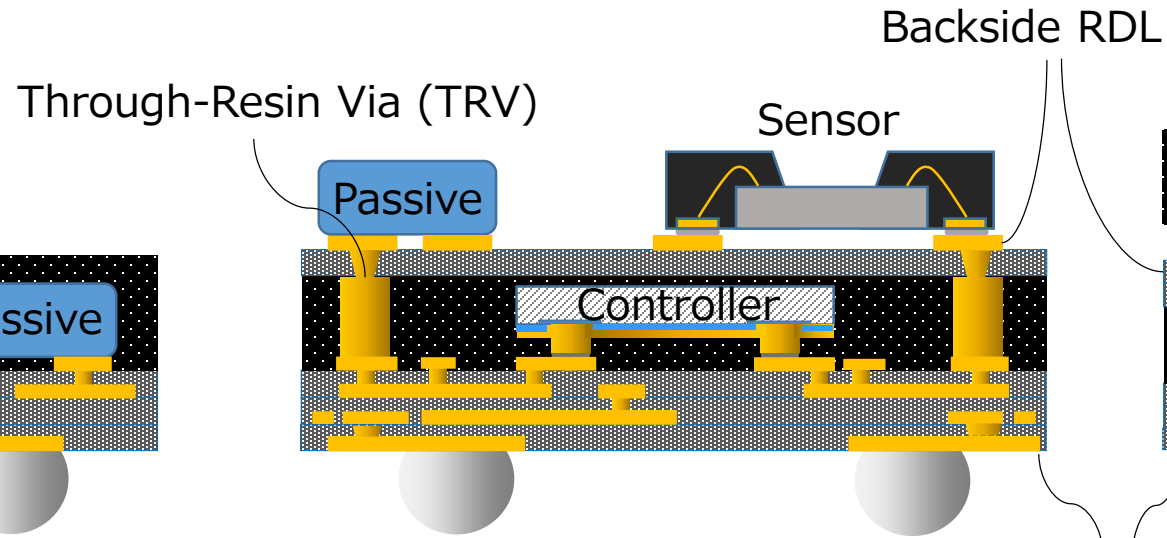
Flexible Structural Design for Various Applications

Epoxy-based RDL-first process enables flexible structural design for various applications.

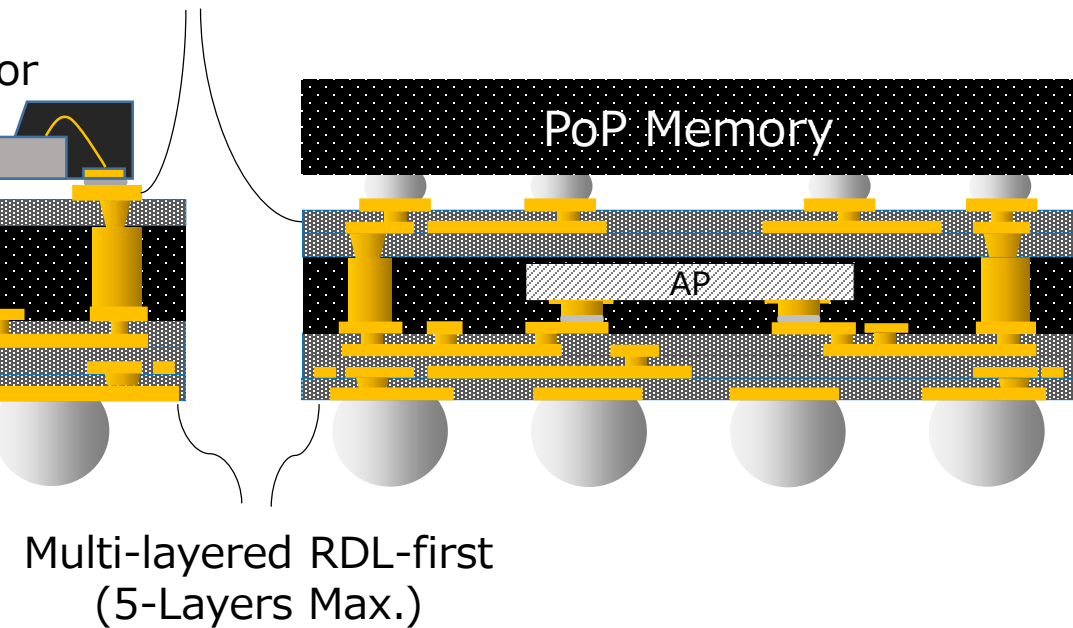
Power Management



Sensor Module

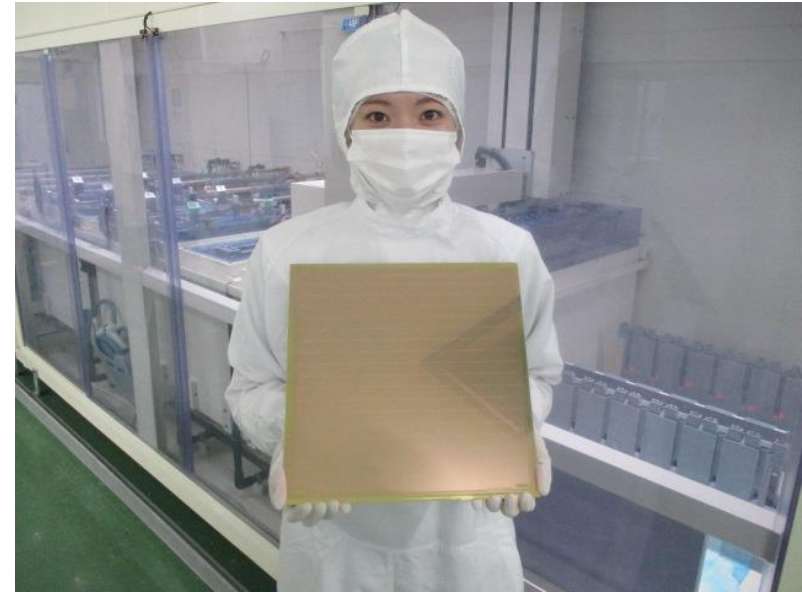


Mobile Processor



FOLP[®] Process Advantage

- 1. High Yield : KG-RDL + KGD Combination
- 2. Short cycle time : Horizontal specialization Process
Wafer Bumping & Substrate (RDL) Process
+ Assembly + Test Process
- 3. Cost effective : Mechanical de-bonding system
MUF(mold under fill) Process
300mm Sq. Panel
- 4. One stop solution in AOI electronics Group.
- 5. High Reliability : Modified Epoxy Resin (High Tg, Low Warpage)
Solder materials of various composition
- 6. High Performance : Good design flexibility
Low Dk, Df substrate materials for RF devices(5G⇒6G)
High heat dissipation, Low impedance for power IC



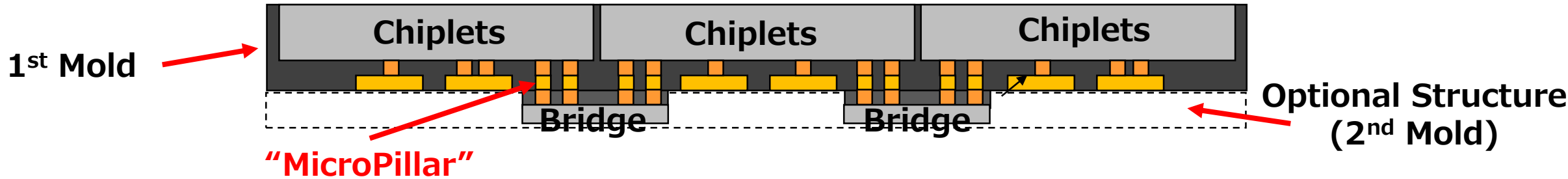
FOLP[®] *for Logic application
(Chiplet integration)*

Conventional Chiplet Integration using “Interposer”

Technology	Si interposer	RDL interposer	Embedded Bridge interposer
Pros	<ul style="list-style-type: none">✓ Technology maturity	<ul style="list-style-type: none">✓ Excellent electrical characteristics✓ Relatively low cost	<ul style="list-style-type: none">✓ Excellent electrical characteristics✓ L/S selectability
Cons	<ul style="list-style-type: none">✓ Electrical characteristics✓ High cost✓ Size limitation (Wafer only)	<ul style="list-style-type: none">✓ Feasibility of fine L/S at panel-level✓ Need bridge assist in case of sub-micron L/S	<ul style="list-style-type: none">✓ Complicated process and structure✓ High cost✓ Limited connection Pitch between bridge and chiplets

"Pillar Suspended Bridge"

AOI proposal



- High positioning accuracy of bridges
- ✓ Face-Down bonder ($\sim 1 \mu\text{m}$)
- ✓ Die shift is avoided by fixing with Micro Pillars
- ✓ Not affected by variations in chip thickness
- Simple process & material handling scheme

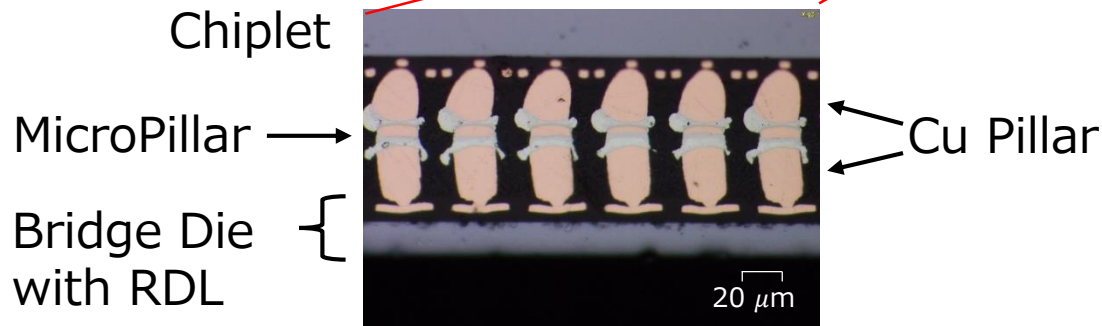
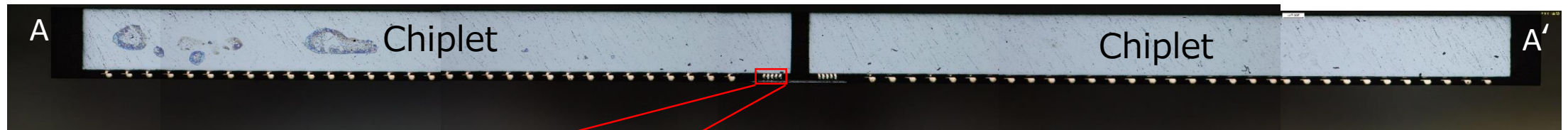
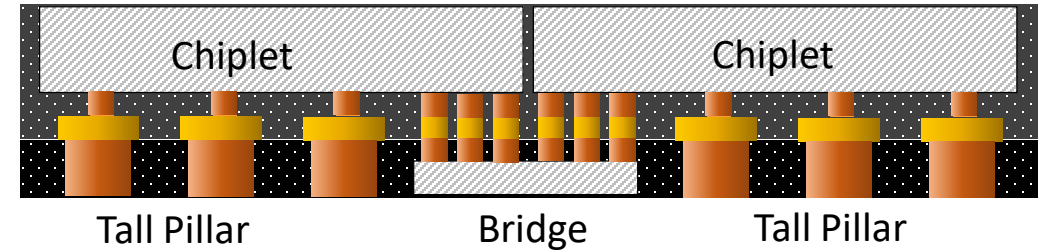
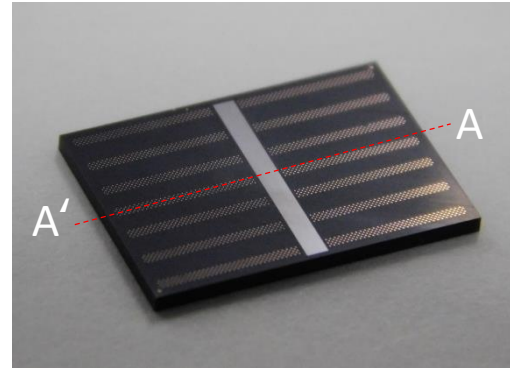
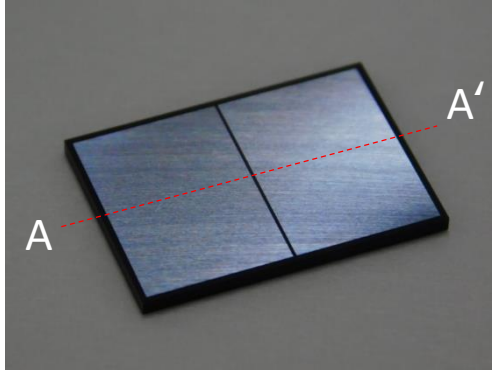


Excellent scalability

- ✓ *Expandability to panel-level processing*
- ✓ *Finer connection pitch for bridge ($< 20 \mu\text{m}$)*

Internal Structure of Proof-of-Concept Sample

Die-to-Die interconnect by 20 μm thick Bridge



- MES2022 “A Simple Die-to-Die Bridge Architecture
“ Evaluation with the Best Paper Award
- IMAPS 2022 “Chiplet Integration by Die-to-Die
Pillar-Suspended Bridge”
- ECTC 2023 “A Novel Chiplet Integration Architecture
Employing Pillar-Suspended Bridge with Polymer
Fine-Via Interconnect”

FOLP[®] *for Power Module application*

Background

■ Applications : Power Supply System



Source : NTT Corporation



Source : TOYOTA corporation

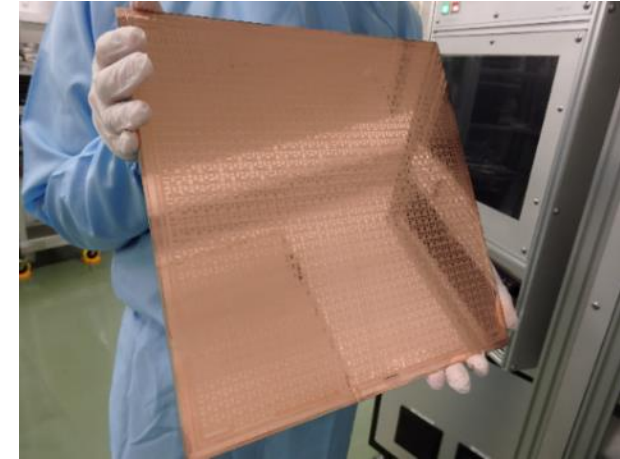
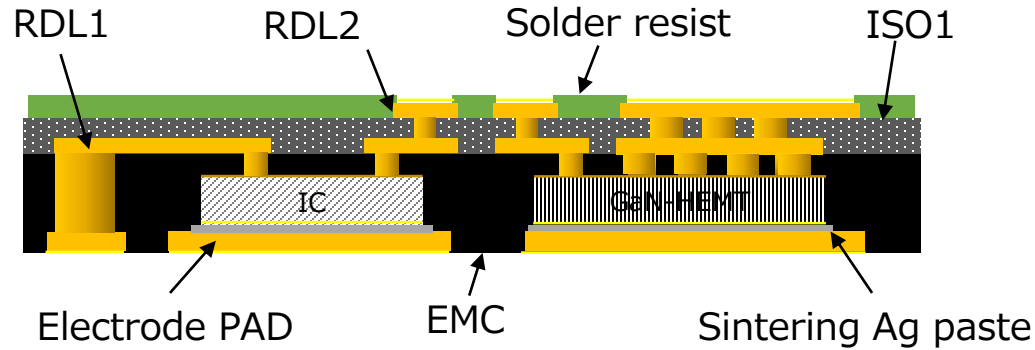
- ✓ Data centers and various power supply equipment shift from 12V to 48V systems.
- ✓ As power supply output current increasing, wiring resistance is a big issue about power distribution loss.
- ✓ Placing the power supply near the processor (CPU/GPU) will be an important for power integrity.
- ✓ Chip-embedded packages (PoP/CoP/3D-SiP) can shrink size and increase current density.

According to Texas Instruments 's white paper, they have brought an average module size reduction of 25 percent annually.

Source : U. Chaudhry et al, SiP Power Modules White Paper "Powerful solutions come in small packages", Texas Instruments, page2

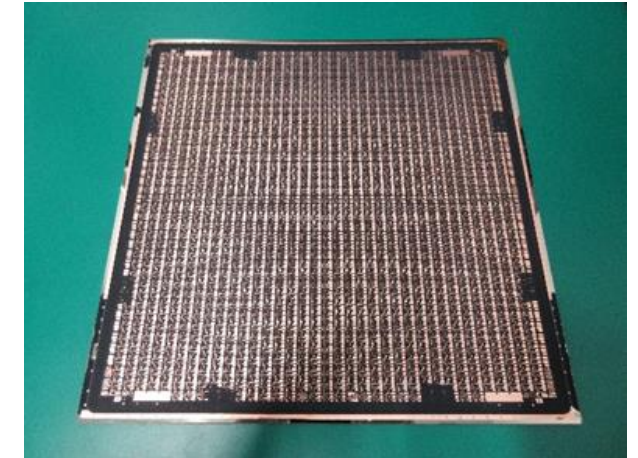
Introduction of Our Coreless Chip Embedded Technology

AOI's new approach of *Ultra thinner, Higher heat dissipation* chip embedded technology in analog and power solutions.



Features of this concept

- Unique Coreless structure
 - ① All Cu plating
 - ② Chip embedded method
 - ③ Power customized fan-out processes
- Excellent thermal property
- SoC-like extra thin packages

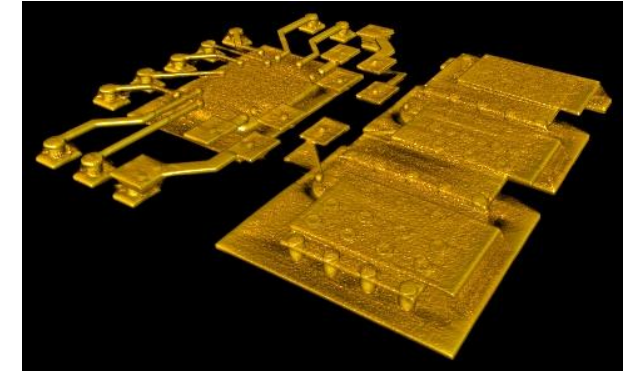
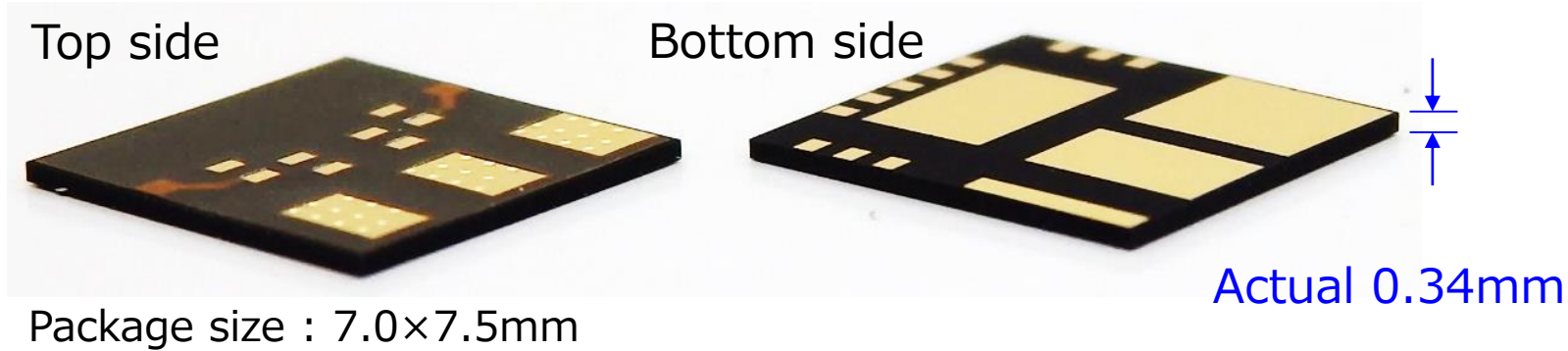


Trial production and evaluations for a Prototype

■ Prototyped package

New Coreless chip embedded module package

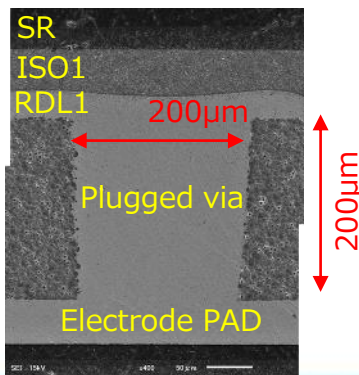
*X-ray CT 3D image
(Internal structure)*



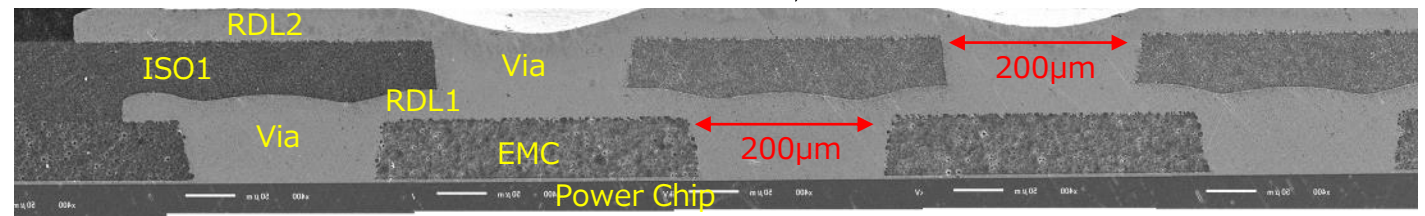
Actual Cross section



Cu plugged via


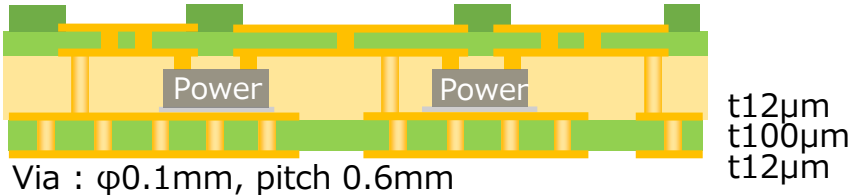
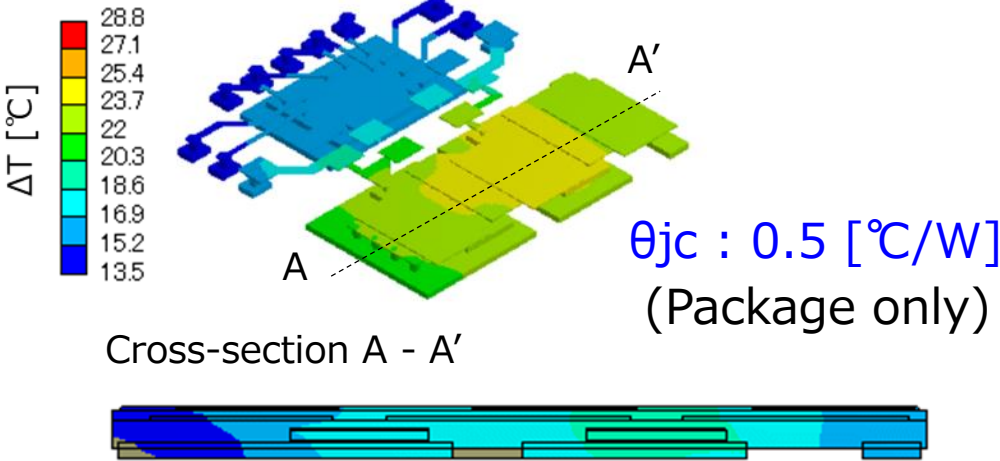
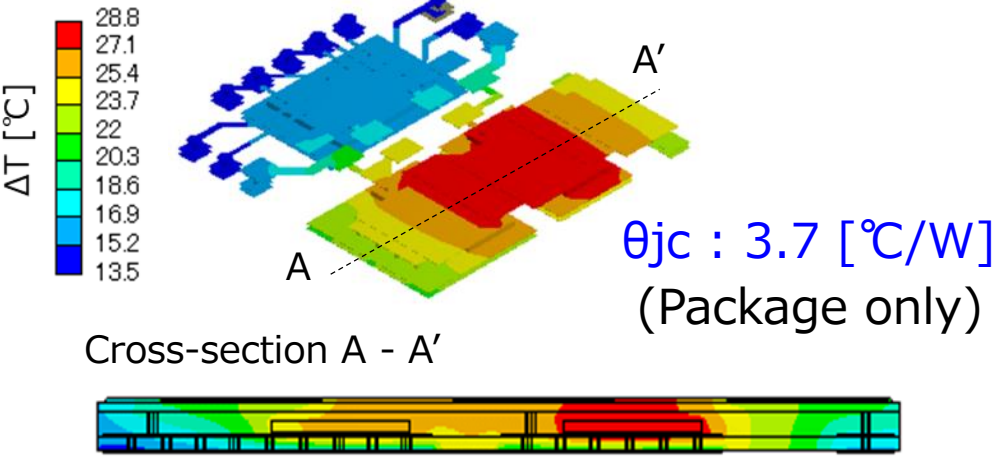


Direct Cu plating connection of power chips



Thermal Resistance Simulation with Our Concept Package

■ Simulation result

	Our Concept package	Prepreg package (assumption)
Structure	 <p>t50µm</p>	 <p>t12µm t100µm t12µm Via : φ0.1mm, pitch 0.6mm</p>
Thermal simulation result	<p>Inside the Package image</p>  <p>ΔT [°C]</p> <p>28.8 27.1 25.4 23.7 22 20.3 18.6 16.9 15.2 13.5</p> <p>θ_{jc} : 0.5 [°C/W] (Package only)</p> <p>Cross-section A - A'</p>	<p>Inside the Package image</p>  <p>ΔT [°C]</p> <p>28.8 27.1 25.4 23.7 22 20.3 18.6 16.9 15.2 13.5</p> <p>θ_{jc} : 3.7 [°C/W] (Package only)</p> <p>Cross-section A - A'</p>

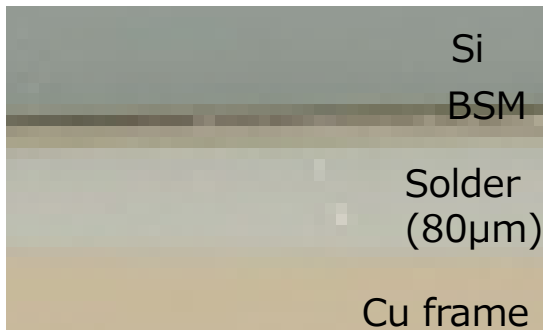
Embedded Multi-Chip in Molded Package

Package structure for Half-Bridge DC/DC converter

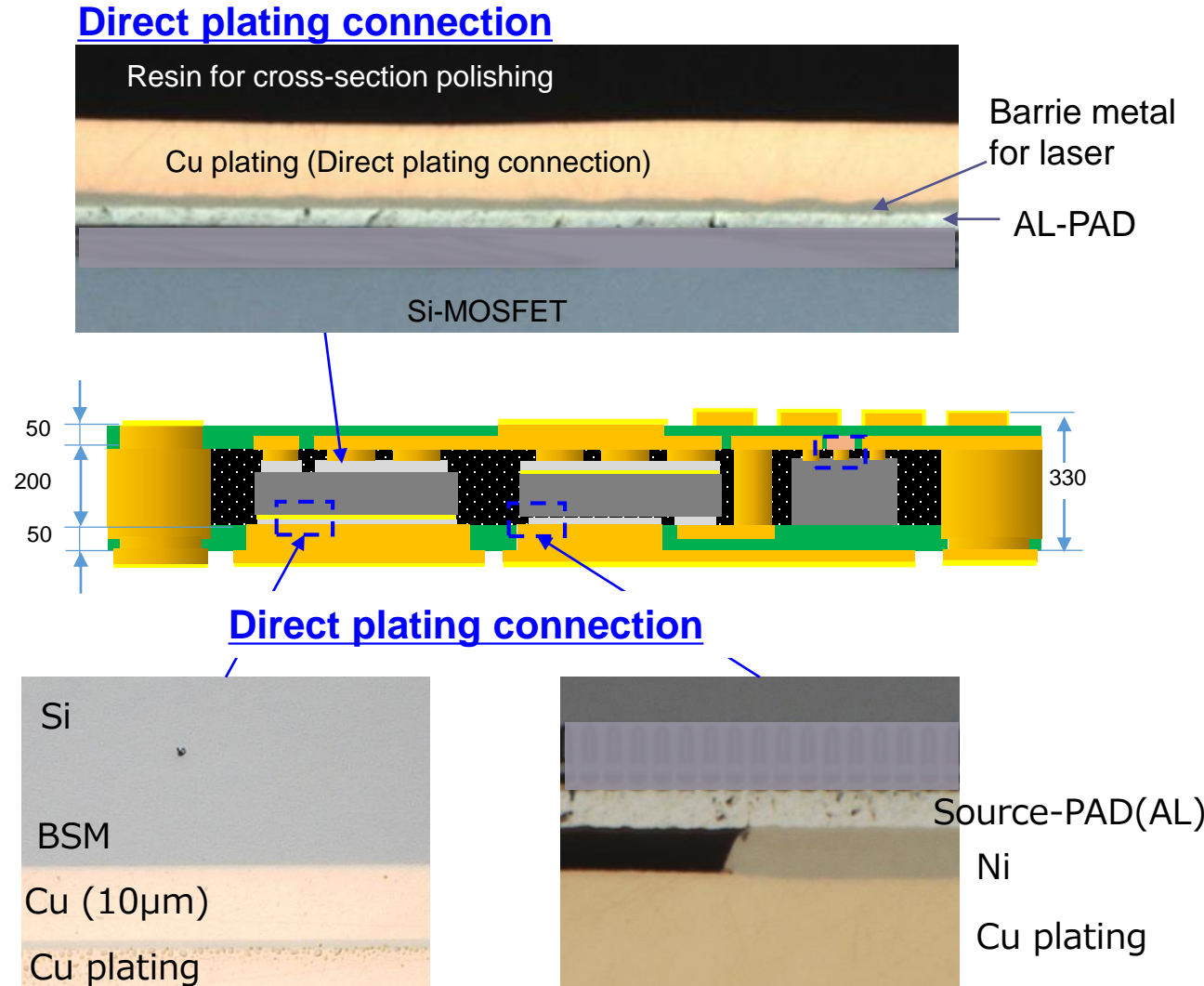
Solderless connect

- ⇒ • Lower impedance
• Lower noise response to high freq. switching

Solder connection



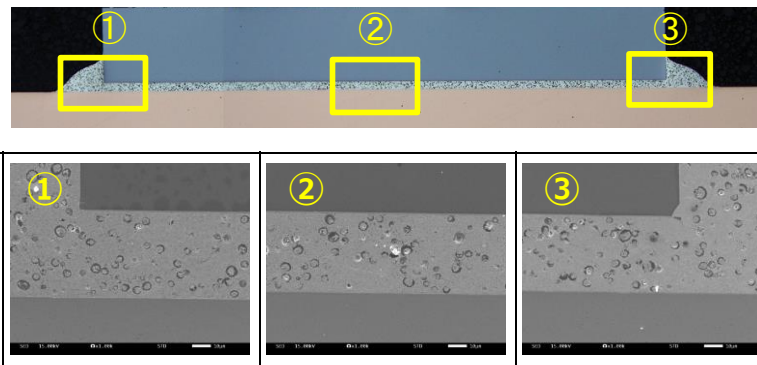
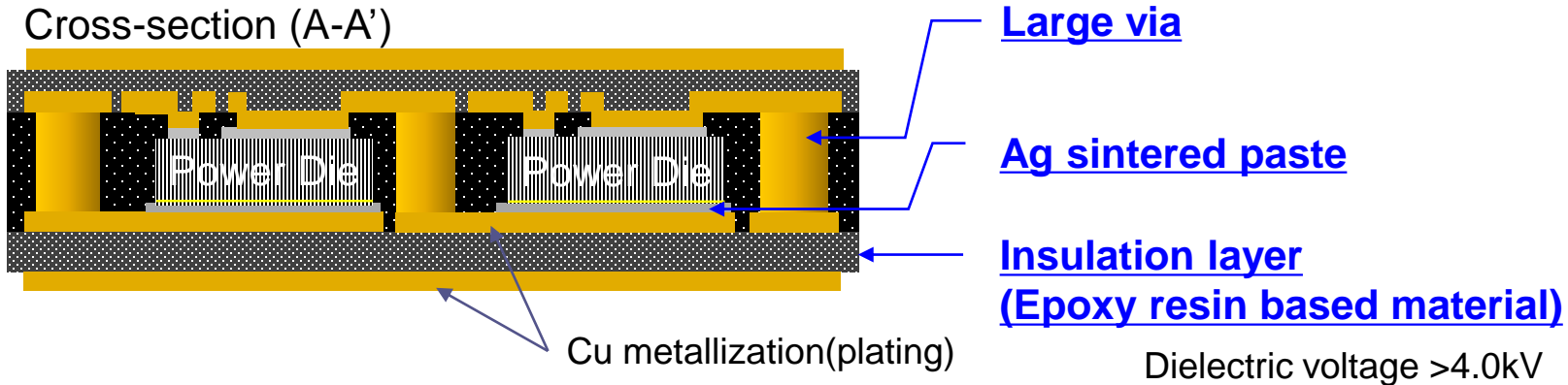
DB material
Electrical conductivity 50times
Thermal conductivity 38times



Package structure for Inverter IC module

Embedded power package without DBC substrate

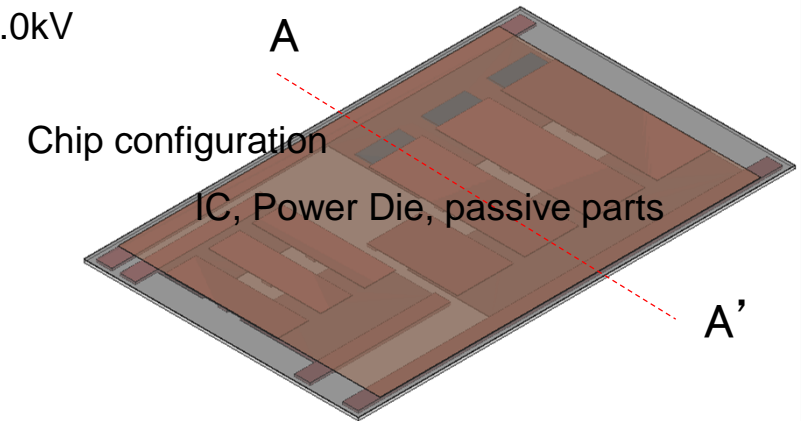
Cross-section (A-A')



Power die Ag sintered paste

Target ; Si, SiC etc.

3D-MODEL

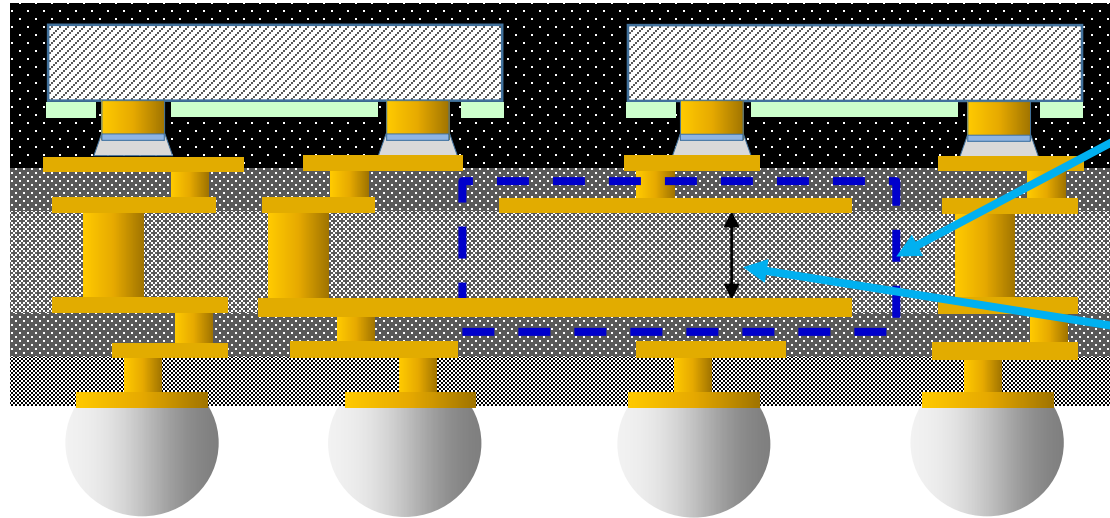


Prototype module

High voltage isolation by FOLP®

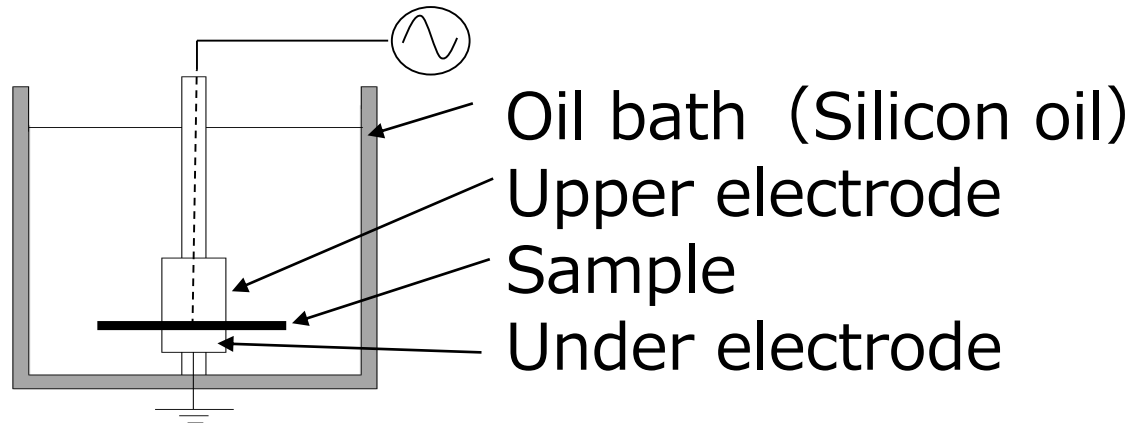
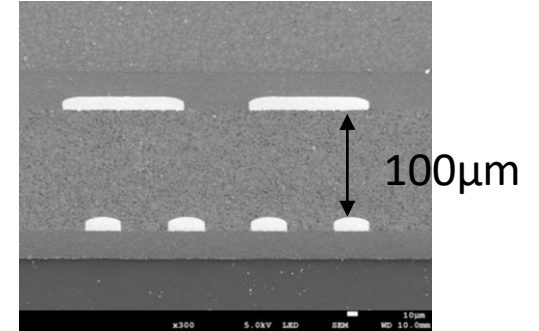
Embedded Coupling Devices

*RDL High Voltage Isolation
for Digital Isolator, Isolation Power supply etc.*



Coupling Device

High Voltage Isolation



Based on ASTM-D149

Isolation(µm)	kV/mm
100	122.7

ATTENTION

This material contains confidential information and it is hereby notified that any disclosure, copying, distribution, or the taking of any action in reliance on the contents of this material is strictly prohibited without a prior written consent of AOI Electronics. Thank you very much for your understanding in advance.